

Symposium (Oral) | Symposium : Advancements in Junction Technologies and Cutting-Edge Si-LSIs: Past, Present, and Future

📅 Thu. Sep 19, 2024 1:30 PM - 4:25 PM JST | Thu. Sep 19, 2024 4:30 AM - 7:25 AM UTC 🏛️ A23 (TOKI MESSE 2F)

[19p-A23-1~5] Advancements in Junction Technologies and Cutting-Edge Si-LSIs: Past, Present, and Future

Osamu Nakatsuka(Nagoya Univ.), Bunji Mizuno(UJTLab), Ichiro Mizushima(NuFrac Technology, Inc.)

3:10 PM - 3:50 PM JST | 6:10 AM - 6:50 AM UTC

[19p-A23-3] Panel Discussion

○Bunji Mizuno¹, Hiroshi Iwai², Hitoshi Wakabayashi³, Ichiro Mizushima⁴, Masayasu Tanjo⁵, John Ogawa Borland⁶, Osamu Nakatsuka^{7,8}, Kazuyoshi Takayama⁹ (1.UJTLab, 2.NYCU, 3.IIR, Tokyo Tech, 4.NuFlare Technology, 5.Retired Nissin Ion, 6.J.O.B. Technologies, 7.Grad. Sch. Eng., Nagoya Univ., 8.IMaSS, Nagoya Univ., 9.kind of happy)

Keywords : Junction Technologies